Special Issue

Reliability and Engineering Applications

Message from the Guest Editors

Reliable processes are critical in various fields including chemical, mechanical, electrical, material, and biomedical engineering with various scales from nano to macro. This Special Issue aims to provide insights for researchers to discuss recent advanced reliable processes and techniques, and applications to address many challenging engineering problems. Unique and novel manufacturing, modeling, and numerical methods of any industrial applications are of special interest.

Guest Editors

Dr. Hongyun So
Dr. Jong-Won Park
Dr. Sunghan Kim

Deadline for manuscript submissions

closed (25 March 2023)

Processes

an Open Access Journal by MDPI

Impact Factor 2.8
CiteScore 5.5

mdpi.com/si/113009

Processes
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
processes@mdpi.com

mdpi.com/journal/processes

Processes

an Open Access Journal
by MDPI

Impact Factor 2.8
CiteScore 5.5

mdpi.com/journal/processes

About the Journal

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

Prof. Dr. Giancarlo Cravotto
Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, AGRIS, and other databases.

Journal Rank:

CiteScore - Q2 (Chemical Engineering (miscellaneous))